

Title (en)
PLASMA PROCESSING APPARATUS

Title (de)
PLASMAVERARBEITUNGSVORRICHTUNG

Title (fr)
APPAREIL DE TRAITEMENT AU PLASMA

Publication
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Application
EP 11761395 A 20110816

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Abstract (en)
[origin: WO2013024235A1] The present invention relates to an apparatus (10) for plasma processing an article(12), the apparatus comprising a chamber(14) for receiving an article to be processed; electrode means (16) for generating an electric and/or magnetic field in said chamber when energised by alternating electrical energy for establishing a plasma in said chamber so that said article can be processed; and varying frequency generating means (20) for generating alternating electrical energy for transmission to the electrode means, said alternating electrical energy being generated at a plurality of different frequencies in succession, one frequency after another frequency, thereby producing a succession of standing waves in said chamber of a plurality of different wavelengths.

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